

Application of the Capacitance-Voltage curve to photovoltaic cell characterizations

I – INTRODUCTION

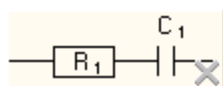
Capacitance measurement is widely used to carry out semiconductor characterization such as those for photovoltaic (PV) cells. For example, this measurement is used to determine the doping concentration.

In EC-Lab® & EC-Lab® Express software, it is possible to directly plot the capacitance (directly means without any post-process). The capacitance can be obtained with all the Electrochemical Impedance Spectroscopy (EIS) techniques *i.e.* Potentio EIS (PEIS), Galvano EIS (GEIS), Staircase PEIS (SPEIS), Staircase GEIS (SGEIS), “Wait” technique that allows user to follow up the modulus of Z vs time (PEISW) techniques.

Depending on the model circuits considered, two types of capacitance, C_s or C_p , are calculated. The capacitance C_s corresponds to the capacitance of the R+C (in series) circuit and C_p corresponds to the capacitance of the R/C (in parallel) circuit (Fig. 1)

	X	Y1	Y2
freq/Hz	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
Re[Z]/Ohm	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
-Im[Z]/Ohm	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
Z /Ohm	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
Phase[Z]/deg	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
time/s	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
<Ewe>/V	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
<I>/mA	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
Cs/μF	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>
Cs-2/μF-2	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
Cp/μF	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>
Cp-2/μF-2	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
cycle number	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>

C_s :



C_p :

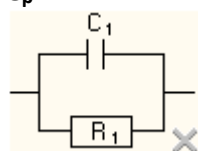


Figure 1: The two equivalent circuits offered for direct capacitance plotting.

This note demonstrates how to plot a Capacitance vs. Voltage (C-V) curve. Firstly, the different options offered to plot the capacitance are shown with a varia-capacitor¹ as an experimental model system. A discussion is given about the selection of the circuit model and a comparison between the capacitance values fitted with ZFit and the capacitance directly available in the technique. Secondly, typical C-V characterizations of PV cell are described.

II – EXPERIMENTAL CONDITIONS

Investigations are carried out with a SP-200 equipped with the Ultra Low Current option or with SP-300 and EC-Lab® software. For both systems (*i.e.* varia-capacitor and photovoltaic cell), investigations were carried out with a standard two-electrode connection.

The characteristics of the varia-capacitor are described below:

- low voltage variable capacitance double diode (BB201 from NXP).

- The capacitance is in the range of 10 to 120 pF for a voltage range of 0.5 to 11V.

The C-V characterization of the PV cell has been performed on a cell irradiated by a Xenon lamp of 150 W (light source of MOS-200 powered by ALX-150 power supply).

III – VARIA-CAPACITOR INVESTIGATIONS

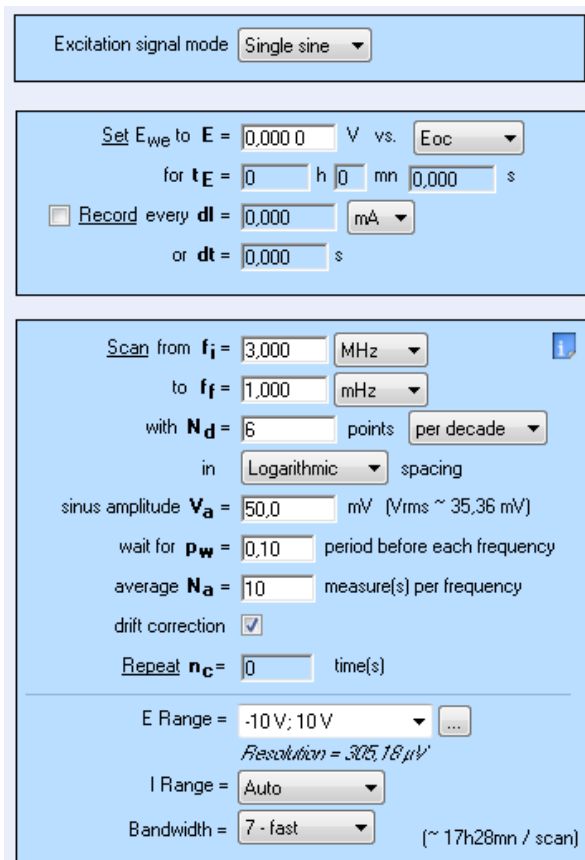
III - 1 R/C OR R+C EQUIVALENT CIRCUIT?

To choose the appropriate equivalent circuit among R/C or R+C, an EIS measurement on a wide frequency range *i.e.* 3 MHz to 1 mHz is performed. Settings are displayed in Fig. 2.

The EIS measurement leads to a semicircle (Fig. 3), so the R/C model (C_p variable) is considered for the C-V investigations. The

¹ A capacitor whose capacitance may be intentionally and repeatedly changed mechanically or electronically

fitted values of R and C are 70 Ohm and 145 pF (Fig. 4), respectively.



Excitation signal mode: Single sine

Set E_{we} to $E = 0,0000$ V vs. E_{oc}

for $t_E = 0$ h 0 mn $0,000$ s

Record every $dI = 0,000$ mA

or $dt = 0,000$ s

Scan from $f_i = 3,000$ MHz

to $f_f = 1,000$ mHz

with $N_d = 6$ points per decade

in Logarithmic spacing

sinus amplitude $V_a = 50,0$ mV ($V_{rms} \sim 35,36$ mV)

wait for $p_w = 0,10$ period before each frequency

average $N_a = 10$ measure(s) per frequency

drift correction

Repeat $n_c = 0$ time(s)

E Range = -10 V; 10 V

Resolution = 305,18 μV

I Range = Auto

Bandwidth = 7 - fast (~ 17h28mn / scan)

Figure 2: Settings for the EIS characterizations of the varia-capacitor.

III - 2 C-V INVESTIGATIONS

Two SPEIS techniques are performed. One in the frequency range from 7 MHz to 1 Hz (setting displayed in Fig. 5) and one at one frequency (with similar settings to those shown in Fig. 5 with f_i equal to f_f). Measurements were performed at a frequency of 323 kHz because above this frequency the responses of the varia-capacitor is dependent on the frequency (Fig. 6). The experiments are named SPEIS_{7MHz 1Hz} and SPEIS_{323kHz}, respectively. The voltage scan starts at 0V and goes up to 10V with steps of 200 mV.

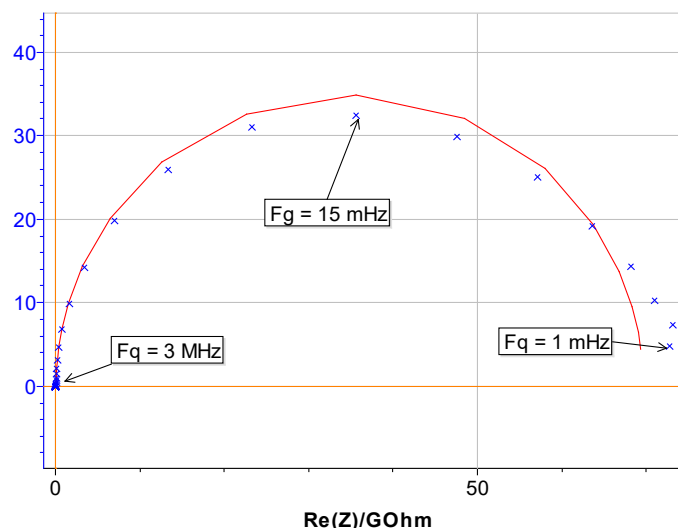
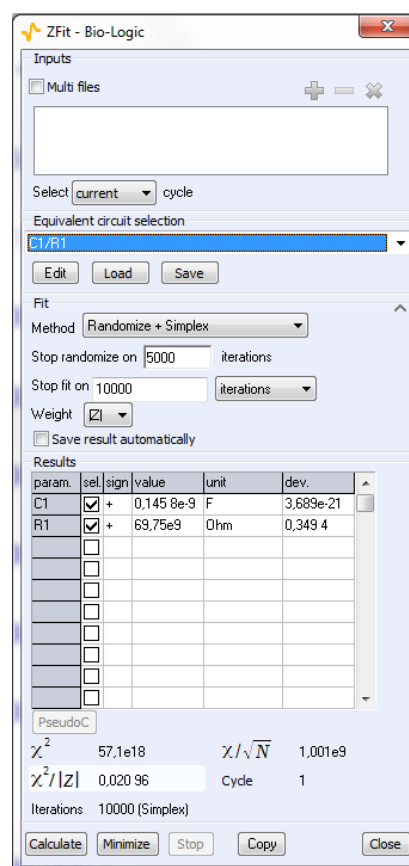


Figure 3: Nyquist plot of varia-capacitor (Exp data fitted data).



Inputs

Multi files

Select current cycle

Equivalent circuit selection: C1/R1

Fit Method: Randomize + Simplex

Stop randomize on 5000 iterations

Stop fit on 10000 iterations

Weight: |Z|

Save result automatically

param.	sel	sign	value	unit	dev.
C1	<input checked="" type="checkbox"/>	+	0,145 8e-9	F	3,689e-21
R1	<input checked="" type="checkbox"/>	+	69,75e9	Ohm	0,349 4
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				

PseudoC

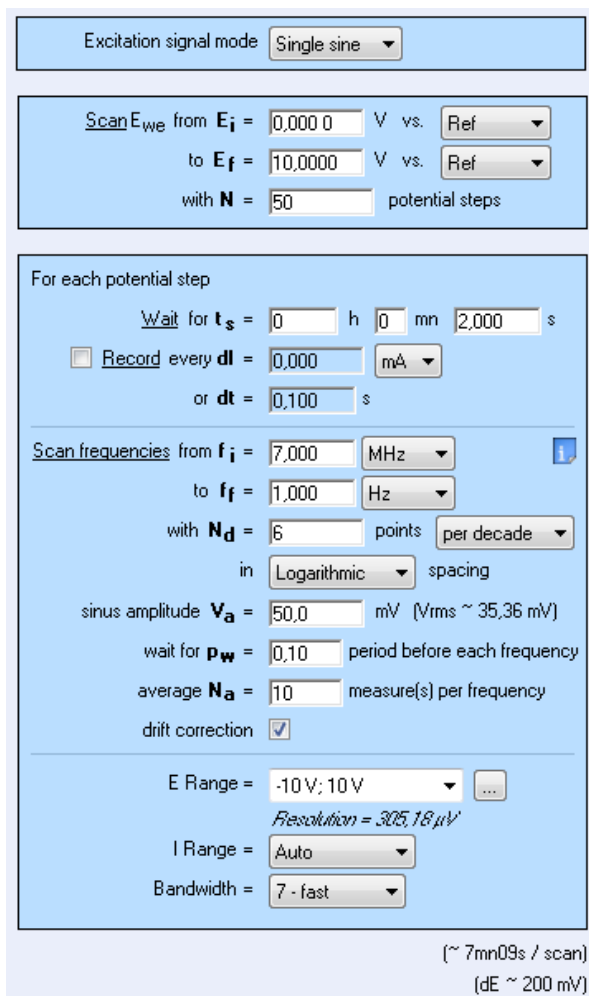
χ^2 57,1e18 χ/\sqrt{N} 1,001e9

$\chi^2/|Z|$ 0,020 96 Cycle 1

Iterations 10000 (Simplex)

Buttons: Calculate, Minimize, Stop, Copy, Close

Figure 4: Values of the Zfit process.



Excitation signal mode: Single sine

Scan E_{we} from $E_i = 0,0000$ V vs. Ref to $E_f = 10,0000$ V vs. Ref with $N = 50$ potential steps

For each potential step
 Wait for $t_s = 0$ h 0 mn $2,000$ s
 Record every $dI = 0,000$ mA or $dt = 0,100$ s

Scan frequencies from $f_i = 7,000$ MHz to $f_f = 1,000$ Hz with $N_d = 6$ points per decade in Logarithmic spacing
 sinus amplitude $V_a = 50,0$ mV ($V_{rms} \sim 35,36$ mV)
 wait for $p_w = 0,10$ period before each frequency
 average $N_a = 10$ measure(s) per frequency
 drift correction

E Range = -10 V; 10 V Resolution = $3025,18 \mu V$
 I Range = Auto
 Bandwidth = 7 - fast

(~ 7mn09s / scan)
 (dE ~ 200 mV)

Figure 5: SPEIS settings for varia-capacitor characterizations.

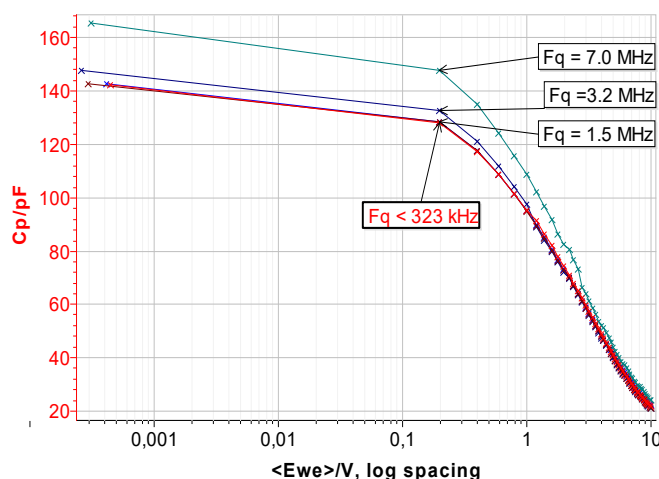


Figure 6: C-V characterization at different frequencies.

The $SPEIS_{7MHz-1Hz}$ allows users to fit the capacitance value, C_1 with the Zfit tool at the different frequencies (window of frequency selection is displayed in Fig. 7). C_1 is compared in Fig. 8 to the value of C_p that is already

calculated during the experiments $SPEIS_{7MHz-1Hz}$ and $SPEIS_{323kHz}$. C_1 and C_p leads to similar values around 140 pF at low voltage and 20 pF at high voltage. So, the comparison shows that the C_1 calculated with Zfit and C_p determined directly in the EIS technique are identical.

These values are in agreement with the specification described in the datasheet of the varia-capacitor.

Moreover, $SPEIS_{7MHz-1Hz}$ and $SPEIS_{323kHz}$ last 6 200 s and 150 s, respectively. So it is possible to save time by performing SPEIS at one frequency.

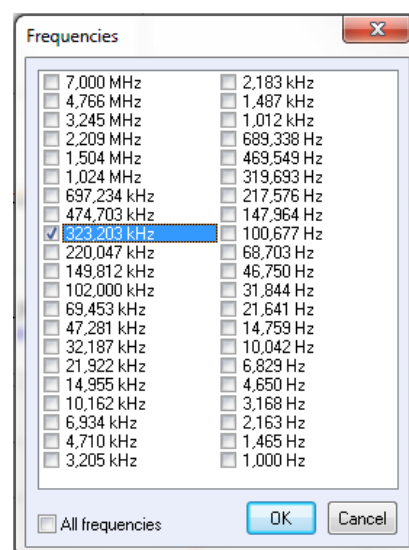


Figure 7: Frequency selection.

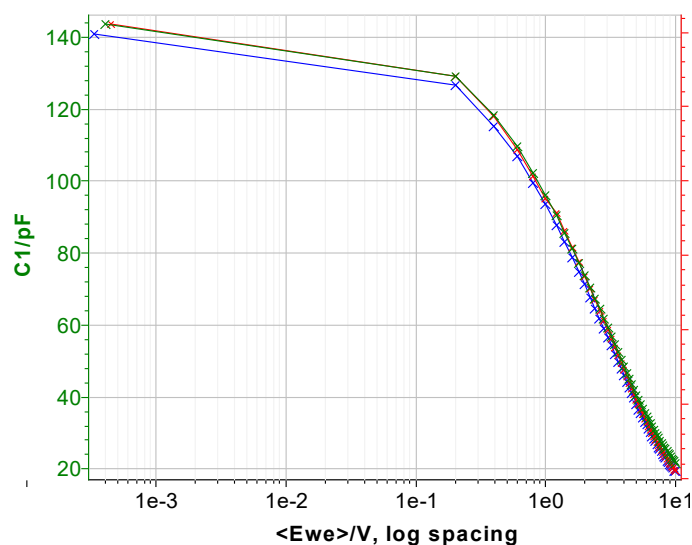


Figure 8: semi logarithmic C-V curves of varia capacitor. C_p vs. E of $SPEIS_{323kHz}$; C_1 (from Zfit) vs. E of $SPEIS_{7MHz-1Hz}$.

IV – C-V CURVE OF PHOTOVOLTAIC CELL

For the PV cell characterization, the voltage is scanned between 3 and 7.5 V and the frequency of the signal is 100 kHz (Fig. 9). According to the application note #24 [1], R/C model is considered. So C_p vs V curve is plotted (Fig. 10).

The C-V curve exhibits 3 regions:

- $E < 4V$: accumulation region
- $4V < E < 6V$: depletion region
- $E > 6V$: Inversion region

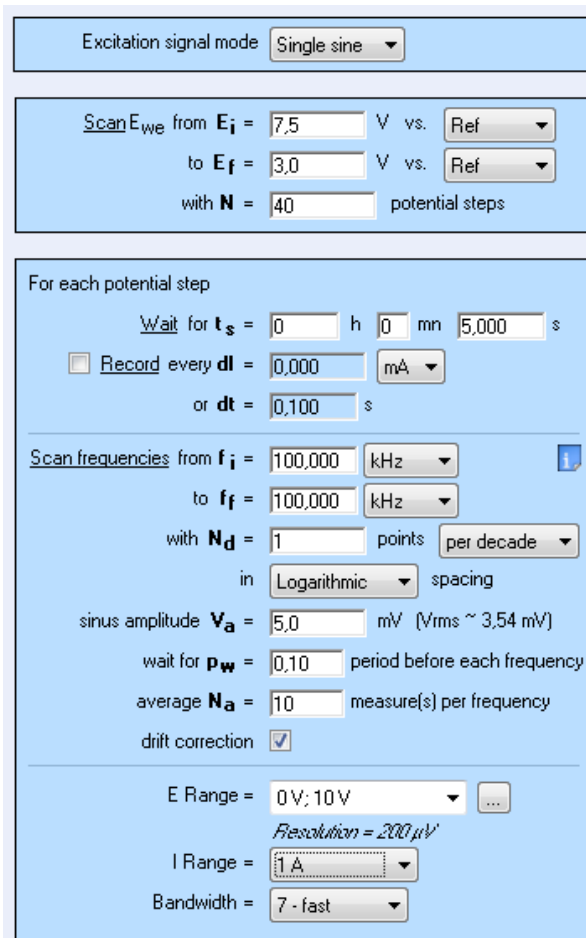


Figure 9: C-V curves settings of PV cell characterization.

The doping concentration N can be determined thanks to the following relationship:

$$N = \frac{2}{e\epsilon\epsilon_0 A^2 \left(\frac{d\left(\frac{1}{C^2}\right)}{dE} \right)} \quad (1)$$

Where e is the electron charge (1.60×10^{-19} C)
 ϵ_0 is the semiconductor permittivity (1.03×10^{-12} F/cm for silicon)
 A is the surface of the photovoltaic cell, 21 cm^2
 C is the capacitance (F) and E the voltage (V).

As C^2 variable is also available in the list of available variable (Fig. 1), it is also possible to plot C^2 vs. E . The slope of this curve leads to the doping concentration.

In this case, the slope (determined by linear fit) is 3.53×10^{15} F/V, so the doping concentration is $1.64 \times 10^{14} \text{ cm}^{-3}$. This value is in agreement with a value previously given [1].

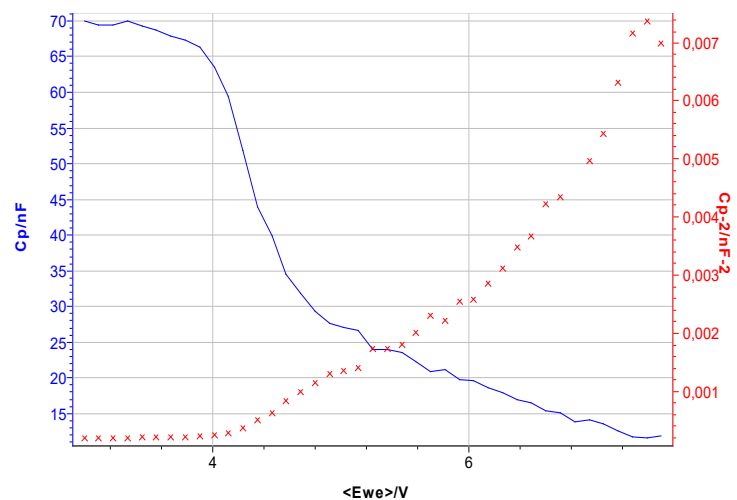


Figure 10: C-V curves of photovoltaic cell. C_p vs. E and C_p^2 vs. E .

IV – CONCLUSION

The note shows how to perform capacitance measurements without any fitting process. This offers several advantages:

- Quick measurement, only one frequency is needed to determine C_p or C_s . No need for the full EIS spectra.
- No post-treatment: no impedance fitting process is needed

- The graphic package of EC-Lab allows one to plot different types of graph such as C vs. E in log spacing, C^2 vs. E , and even more...

It is possible to follow up the capacitance change that can be carried out with the PEISW technique. This technique is also of interest for sensor applications.

Data files can be found in :

C:\Users\xxx\Documents\EC-Lab\Data\Samples\Photovoltaic\X_C_V_Character

REFERENCES

- 1) [Application Note #24](#) “Photovoltaic Characterizations: Polarization and Mott-Schottky plot”

Revised in 08/2019